

Application No.: 10/612184
Docket No.: HP0070USNA

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REMARKS

Applicants respectfully request favorable reconsideration for the following reasons:

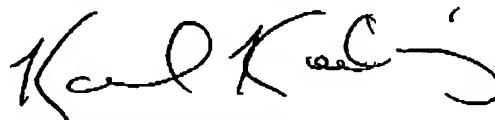
1. The original numbering of the claims has been preserved and properly corrected in accordance with the Examiner's comments.
2. Regarding 35 U.S.C. Sections 102(e) and 103(a):
 - a. Claims 1 and 2 have been combined and the resistivity ranges have been narrowed, thereby limiting the present invention to a particular type of oriented film (or precursor thereto) having a volume resistivity at least an order of magnitude greater than the surface resistivity;
 - b. neither Chacko (USP 6,617,377) nor Schlueter et al. (USP 6,201,945) disclose a film drawing (stretching) technology to modify resistivities in this manner; and
 - c. the amended claims are now directed to a particular type of film (or precursor thereto) having improved (advantageous) electrostatic dissipation properties, where an applied charge will preferentially dissipate at the surface (in contradistinction to permeating through the volume).

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In view of the foregoing, allowance of the above-referenced application is respectfully requested.

Respectfully submitted,



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